

WE CLAIM:

1. A process for producing a carboxylic acid/diol mixture, said process comprising:
 - (a) removing in a liquor exchange zone impurities from a
5 carboxylic acid slurry to form a water-wet carboxylic acid cake, a mother liquor stream, a solvent mother liquor stream, and a solvent/water byproduct liquor stream;
 - (b) routing said water-wet carboxylic acid cake to a vapor seal zone; and
 - 10 (c) adding at least one diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.
2. A process according to claim 1 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid,
15 naphthalene dicarboxylic acid, trimellitic acid, and mixtures thereof.
3. A process according to claim 1 or 2 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 20 4. A process according to claim 1 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

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5. A process according to claim 1 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.
6. A process for producing a carboxylic acid/diol mixture, said process comprising:
- 5 (a) removing in a solvent liquor exchange zone impurities from a carboxylic acid slurry to form a carboxylic acid cake with solvent, a mother liquor stream, and a solvent mother liquor stream;
- (b) adding water in a water wash zone to said carboxylic cake with solvent to produce a water-wet carboxylic acid cake and a
- 10 solvent/water by product liquor stream;
- (c) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (d) adding at least one diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol
- 15 mixture.
7. A process according to claim 6 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.
8. A process according to claim 6 or 7 wherein said diol is selected
- 20 from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.

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9. A process according to claim 6 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 5 10. A process according to claim 6 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.
11. A process for producing a carboxylic acid/diol mixture, said process comprising:
- (a) removing in a solid-liquid separation zone impurities from a
10 carboxylic acid slurry to form a slurry or cake carboxylic acid product and a mother liquor stream;
- (b) removing in a solvent-water liquor exchange zone residual impurities from said slurry or cake carboxylic acid product to form a water-wet carboxylic acid cake, a solvent mother liquor stream, and a
15 solvent/water byproduct liquor stream;
- (c) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (d) adding at least one diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol
20 mixture.
12. A process according to claim 11 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.

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13. A process according to claim 11 or 12 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 5 14. A process according to claim 11 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
15. A process according to claim 11 wherein said carboxylic acid is...
- 10 terephthalic acid and said diol is ethylene glycol.
16. A process for producing a carboxylic acid/diol mixture, said process comprising the following steps:
- (a) removing a solvent from a slurry or cake carboxylic acid... product in a solvent-water liquor exchange zone; wherein a substantial
- 15 portion of the solvent in said slurry or cake carboxylic acid product is replaced with water to form a water-wet carboxylic acid cake;
- (b) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (c) adding at least one diol to said water-wet carboxylic acid cake
- 20 in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.

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17. A process according to claim 16 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic and mixtures thereof.

18. A process according to claim 16 or 17 wherein said diol is selected
5 from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.

19. A process according to claim 16 wherein said carboxylic acid/diol
10 mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

20. A process for producing a terephthalic acid/diol mixture, said process comprising:

(a) removing in a solvent wash zone residual impurities from a
15 slurry or cake terephthalic acid product to form a terephthalic acid cake with acetic acid;

(b) removing a substantial portion of a solvent in a water wash
zone from said terephthalic acid cake with acetic acid to form a water-wet
terephthalic acid cake; and

20 (c) routing said water-wet terephthalic acid cake to a vapor seal zone; and

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(d) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.

21. A process according to claim 20 wherein said solvent wash zone
5 comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
22. A process according to claim 21 wherein said water wash zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
- 10 23. A process according to claim 20 or 21 wherein said adding occurs at a temperature between about 40 °C to about 290 °C.
24. A process according to claim 20 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol,
15 cyclohexanedimethanol, and mixtures thereof.
25. A process according to claim 20 wherein said diol is ethylene glycol.
26. A process according to claim 20 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification
20 reactor.
27. A process for producing a terephthalic acid/diol mixture, said process comprising:

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- (a) removing a solvent from a slurry or cake terephthalic acid product in a solvent-water liquor exchange zone; wherein a substantial portion of the solvent in said slurry or cake terephthalic acid product is replaced with water to form a water-wet terephthalic acid cake;
- 5 (b) routing said water-wet terephthalic acid cake to a vapor seal zone; and
- (c) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.
- 10 28. A process according to claim 27 wherein said solvent liquor exchange zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
29. A process according to claim 27 wherein said adding occurs at a temperature between about 40 °C and 290 °C.
- 15 30. A process according to claim 27 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
31. A process according to claim 27 wherein said diol is ethylene glycol.
- 20 32. A process according to claim 27 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

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33. A process for producing a terephthalic acid/diol mixture, said process comprising:

(a) removing in a solvent wash zone residual impurities from a slurry or cake terephthalic acid product from a terephthalic acid cake with acetic acid; wherein said solvent wash zone comprises at least one solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C ;

(b) removing a substantial portion of a solvent in a water wash zone from said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; wherein said water wash zone comprises at least one solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C;

(c) routing said water-wet terephthalic acid cake to a vapor seal zone; and

(d) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture; wherein said adding occurs at a temperature between about 40 °C to about 290 °C; wherein said diol is ethylene glycol.

34. A process for producing a carboxylic acid/diol mixture, said process comprising:

(a) removing in a solid-liquid separation zone impurities from a carboxylic acid slurry to form a slurry or cake carboxylic acid product and a mother liquor stream;

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(b) adding solvent to a slurry or cake carboxylic acid product in a solvent wash zone to said slurry or cake carboxylic acid product to produce a carboxylic acid cake with solvent and a solvent mother liquor stream;

(c) optionally, adding water in a water wash zone to said
5 carboxylic cake with solvent to produce a water-wet carboxylic acid cake and a solvent/water by product liquor stream;

(d) routing said water-wet carboxylic acid cake or said carboxylic acid cake with solvent to a vapor seal zone; and

(e) adding at least one diol to said water-wet carboxylic acid cake
10 in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.

35. A process according to claim 34 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.

15 36. A process according to claim 34 or 35 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.

37. A process according to claim 34 wherein said carboxylic acid/diol
20 mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

38. A process according to claim 34 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.

39. A process for producing a terephthalic acid/diol mixture, said process comprising:

5 (a) removing in a solid-liquid separation zone impurities from a terephthalic acid slurry to form a slurry or cake terephthalic acid product and a mother liquor stream;

(b) adding solvent in a solvent wash zone to said slurry or cake terephthalic acid product to produce a terephthalic acid cake with solvent
10 and a solvent mother liquor stream;

(c) optionally, adding water in a water wash zone to said terephthalic acid cake with solvent to produce a water-wet terephthalic acid cake and a solvent/water by product liquor stream;

(d) routing said water-wet terephthalic acid cake or said
15 carboxylic acid cake with solvent to a vapor seal zone; and

(e) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.

40. A process according to claim 39 wherein said solvent wash zone
20 comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.

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41. A process according to claim 40 wherein said water wash zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
42. A process according to claim 39 or 40 wherein said adding occurs at
5 a temperature between about 40 °C and about 290 °C.
43. A process according to claim 39 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 10 44. A process according to claim 39 wherein said diol is ethylene glycol.
45. A process according to claim 39 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 15 46. A process according to claim 34 or 39 wherein said solvent is added counter current to the flow of said slurry or cake carboxylic acid product.
47. A process according to claim 34 or 39 wherein said water is added counter current to the flow of said carboxylic acid cake with solvent.
48. A process according to claim 46 wherein said water is added counter
20 current to the flow of said carboxylic acid cake with solvent.
49. A process according to claim 48 wherein said water wash zone comprises from about 2 to about 4 stages of water counter current washes.

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50. A process according to claim 46 wherein said solvent wash zone comprises from about 2 to about 4 stages of solvent counter current washes.

51. A process according to claim 47 wherein said water wash zone
5 comprises from about 2 to about 4 stages of water counter current washes.